



**St. Joseph's Institute of Technology**  
**St. Joseph's Group of Institutions**  
OMR, Chennai - 119

**Department of Electronics and Communication Engineering**  
(Accredited by NBA)

**FACULTY DETAILS**

<b>Staff Name:</b>	<b>Dr.R.NIROSHA</b>
<b>Designation:</b>	Assistant Professor
<b>Date of Birth:</b>	09-06-1988
<b>Educational Qualification:</b>	M.E.,Ph.D
<b>Area of Interest:</b>	Semiconductor Devices, Healthcare Technology, and Wireless Communication.
<b>Years of Experience:</b>	5 Year & 7 Months
<b>Area of Research:</b>	Semiconductor Devices
<b>No. of Students Project Guided</b>	2
<b>FDP &amp; Workshop Funding</b>	
<b>R &amp; D Activities</b>	
<b>Publications Details</b>	<p><b>SCI/SCOPUS INTERNATIONAL JOURNALS</b></p> <ul style="list-style-type: none"><li>• <b>Nirosha. R.</b>, and Rajesh Agarwal. "Dual-Gate Dual-Contact Integrated Silicon Based Organic Thin Film Transistor for Analog and Digital Applications." <i>Silicon</i> <b>14</b>, no. 12 (2022): 6661-6677. <b>Impact Factor: 2.941.</b></li><li>• <b>Nirosha.R.</b>, and Rajesh Agarwal. "Comprehensive Temperature-Dependent DC Characterization of Organic Thin Film Transistor for Sensing Applications." <i>IEEE Sensors Journal</i> <b>22.17</b> (2022): 16794-16803. <b>Impact Factor:4.325.</b></li><li>• <b>R. Nirosha</b> and R. Agarwal, "Microelectronics Reliability" Characterization and modeling of threshold voltage for organic and amorphous thin-film transistors," <i>Microelectron. Reliab.</i>, vol. 147, no. June, p. 115054, 2023, doi: 10.1016/j.microrel.2023.115054. <b>Impact Factor:1.418.</b></li><li>• <b>Nirosha R.</b>, and Rajesh Agarwal. "Gate dielectric based steady state &amp; transient analysis of channel characteristics for organic thin-film transistors." <i>Journal of Materials Science: Materials in Electronics</i> <b>34.31</b> (2023): 2120. <b>Impact Factor:2.779.</b></li><li>• Singh, A.K., Misra, R., Wadhwa, G., <b>Nirosha.R</b> and Agarwal, R.,</li></ul>

	<p>2022, September. Design and Performance Analysis of Partially Depleted and Fully Depleted Silicon on Insulator MOSFET. In <i>Journal of Physics: Conference Series</i> (Vol. 2335, No. 1, p. 012042). IOP Publishing. <b>Impact Factor:0.547.</b></p> <ul style="list-style-type: none"> <li>• <b>R. Nirosha</b>, Biometric watermarking Techniques in Frequency Domain In <b>International Journal of Applied Engineering Research.</b></li> </ul> <p><b>PATENT PUBLISHED:</b></p> <ul style="list-style-type: none"> <li>• A patent for "AN INTEGRATED DUAL-GATE DUAL INSULATING CONTACT (IDGDC) SILICON BASED ORGANIC THIN FILM TRANSISTOR" by Rajesh Agarwal and <b>R. Nirosha</b> has been published in <b>Indian Patent Application No. 202241042265</b> dated 23/07/2022.</li> </ul> <p><b>SCOPUS INDEXED INTERNATIONAL CONFERENCES</b></p> <ul style="list-style-type: none"> <li>• Nirosha R, Agarwal R. <b>Study of Contact Resistance in Amorphous Zinc Oxide Based Thin-Film Transistors.</b> IEEE 3rd Global Conference for Advancement in Technology (GCAT) 2022 Oct 7 (pp. 1-6). IEEE</li> <li>• R. Nirosha, Rajesh Agarwal, and T. Rama Rao. <b>Dual-Gate Integrated Organic Thin Film Transistor for Digital Applications.</b> 1<sup>st</sup> International Conference of Electronics, Photonics and Smart Technologies (ICePhaST-2020) Vol-1,2020, ISBN 978-93-84136-20-8. (Received as the “Best Paper Award” <b>ICePhaST-2020</b>).</li> <li>• R. Nirosha, Aishiki Halder, Rajesh Agarwal, Vaishnavi upendran. <b>Analysis of the Effect of Different Electrical and Physical Parameters on Contact Resistance in Organic Thin Film Transistors and Optimization Using Machine Learning.</b> 2<sup>nd</sup> International Conference on Recent Advances in Electrical, Electronics, Ubiquitous Computational Intelligence (RAEEUCCI-2023). (PRESENTED) (Received as the “Best paper Award”, <b>RAEEUCCI-2023</b>).</li> </ul> <ol style="list-style-type: none"> <li>1. Demonstrated a project titled “<b>Organic Thin Film Transistor</b>” has won <b>THIRD</b> in the project EXPO part of 2<sup>nd</sup> International Conference on Recent Advances in Electrical, Electronics, Ubiquitous Computational Intelligence (RAEEUCCI-2023).</li> </ol>
<p><b>FDP &amp; Workshop Attended Details</b></p>	<ul style="list-style-type: none"> <li>• Industrial applications of embedded systems and IOT between 22/8/24 and 28/8/24 organized by Rajalakshmi Engineering College.</li> </ul>

	<ul style="list-style-type: none"> <li>• Attended a Five Days Summer School on “<b>Emerging Devices and Circuits to Mimic Biologically Plausible Neuronal Functionalities for Neuromorphic Computing</b>”, organised by IEEE EDS Student Branch Chapter in association with Department of ECE at <b>IITDM, Kancheepuram</b>, held during 19<sup>th</sup>-23<sup>th</sup>Dec 2022.</li> <li>• Attended a One Professional Development Hour on “<b>Compact Models for Circuit Simulation of Component-Level ESD</b>”, organised by <b>IEEE Electron Devices Society Delhi Chapter-India</b> during 25<sup>th</sup> July 2022.</li> <li>• Attended a STTP on “<b>Research Opportunities in Semiconductor Materials and Devices</b>” <b>ROSMD-2021</b> organised by <b>IITDM, Kancheepuram</b>, held on 22-26 October 2021.</li> <li>• Attended a Webinar on “<b>Semiconductor Device Modelling using Silvaco TCAD</b>” organized by <b>Cognitive Design Technology Pvt, Bangalore, India</b> on 7<sup>th</sup> May 2021.</li> <li>• Attended a three-day webinar series on “<b>Solar Cell and Organic Thin Film Transistor for Wearable Applications</b>” organized by <b>IE(I), Kattankulathur Local Centre &amp; Department of Electronics and communication Engineering, SRM Institute of Science and Technology</b> from February 3<sup>rd</sup>-5<sup>th</sup> 2021.</li> <li>• Attended a Six Days Faculty Development Programme on “<b>Recent Advancement in Organic &amp; Nano Electronics RAONE 21</b>” organized by Department of Electronics and communication Engineering, <b>SRM Institute of Science and Technology</b> during 8<sup>th</sup>- 13<sup>th</sup> October 2021.</li> <li>• Attended Faculty Development Programme on “<b>Recent Advancements in Semiconductor Technologies-RASET</b>” in <b>SRM Institute of Science and Technology</b>, on October 9<sup>th</sup> - 14<sup>th</sup> 2020</li> </ul>
<b>NPTEL Courses</b>	NIL
<b>Professional Membership</b>	Member of IAENG